TECHNICAL SPEC FOR Stepper 2 (tool not complete) System Model: Canon FPA 2000 i1, SN: 205 268i1 Tool has been shut down by Litho tech. Electricity, cooling water, Vacuum and CCA are closed. Cables between Main unit and power box are still connected, locking kit and demounting for be provided by buyer. Wafer size: 6 inch Wafer type: Jeida flat **Chuck type: Ring chuck** Reticle changer type: I1 box 14 reticles, standard Inline right or left: Left Particle checker (PPC): NO Touch panel type: Canon standard **Options: None** Reticle size: 5 inch Reticle alignment: Reticle rotation repeatability <= 0.03 um Wafer alignment: <=0.15 um Auto focus: <= 0.15 um **Auto feeder: Yes** Wafer tilt: Wafer feeder:

Track interface: Yes (stepper was used inline with track, track interface is track part

Laser: HeNe

| Lens data: |
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| Stage and U-lens at shutdown Intensity: 250 mW/cm2 Distortion: <= 0.07 um Uniformity: 7.5% |
| Used for 0.35micron line and space? No |
| Chuck maintenance tool: No |
| Reticle bar code reader: Yes |
| Cassette bar code reader: No |
| SW Version: |
| OS: |
| Vintage:1993 |

Missing/defective parts: Several missing parts